

## NJ1800D Process

### Silicon Junction Field-Effect Transistor

#### • Ultra Low-Noise Pre-Amplifier

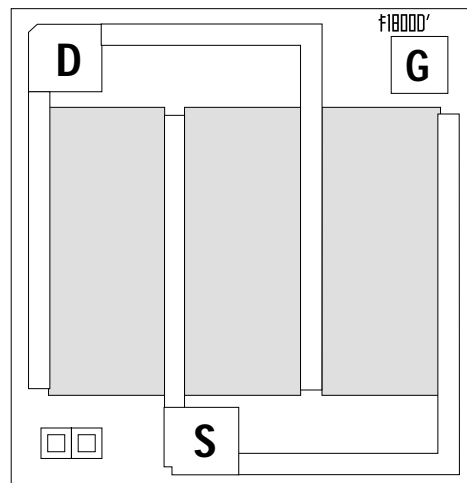
#### Absolute maximum ratings at TA = 25 °C

Gate Current, I <sub>G</sub>	10 mA
Operating Junction Temperature, T <sub>J</sub>	+150°C
Storage Temperature, T <sub>S</sub>	- 65°C to +175°C

#### Devices in this Databook based on the NJ1800D Process.

#### Datasheet

U290, U291



Die Size = 0.052" X 0.052"  
 All Bond Pads ≥ 0.004" Sq.  
 Substrate is also Gate.

At 25°C free air temperature:

#### Static Electrical Characteristics

		NJ1800D Process						
		Min	Typ	Max	Unit	Test Conditions		
Gate Source Breakdown Voltage	V <sub>(BR)GSS</sub>	- 20	- 30		V	I <sub>G</sub> = - 1 μA, V <sub>DS</sub> = 0V		
Reverse Gate Leakage Current	I <sub>GSS</sub>		- 30	- 100	pA	V <sub>GS</sub> = - 10V, V <sub>DS</sub> = 0V		
Drain Saturation Current (Pulsed)	I <sub>DSS</sub>	50		1000	mA	V <sub>DS</sub> = 10V, V <sub>GS</sub> = 0V		
Gate Source Cutoff Voltage	V <sub>GS(OFF)</sub>	- 0.1		- 7	V	V <sub>DS</sub> = 10V, I <sub>D</sub> = 1 nA		

#### Dynamic Electrical Characteristics

Forward Transconductance (Pulsed)	g <sub>fs</sub>		350		mS	V <sub>DS</sub> = 10V, V <sub>GS</sub> = 0V	f = 1 kHz
Drain Source ON Resistance	r <sub>ds(on)</sub>	2		7	Ω	I <sub>D</sub> = 1 mA, V <sub>GS</sub> = 0V	f = 1 kHz
Input Capacitance	C <sub>iss</sub>		100		pF	V <sub>DS</sub> = 10V, V <sub>GS</sub> = 0V	f = 1 MHz
Feedback Capacitance	C <sub>rss</sub>		50		pF	V <sub>DS</sub> = 10V, V <sub>GS</sub> = 0V	f = 1 MHz



InterFET Corporation  
 1000 N. Shiloh Road, Garland, TX 75042  
 (972) 487-1287 FAX (972) 276-3375

[www.interfet.com](http://www.interfet.com)

# NJ1800D Process

---

## Silicon Junction Field-Effect Transistor

